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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/604,190	06/30/2003	. Bruce B. Doris	FIS920030152	1189
•	7590 05/25/2004 ONAL BUSINESS MA	ACHINES CORPORATION	EXAM VU, D	
BLDG. 300-48			ART UNIT	PAPER NUMBER
2070 ROUTE : HOPEWELL J	52 UNCTION, NY 12533		2818	
			DATE MAILED: 05/25/2004	4

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)	
	10/604,190	DORIS ET AL.	
Office Action Summary	Examiner	Art Unit	
<u> </u>	DAVID VU	2818.	سبحا
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet with the c	correspondenc address	<u>·                                      </u>
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.1: after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period v - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, may a reply be timely within the statutory minimum of thirty (30) days will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	mely filed  ys will be considered timely.  the mailing date of this communication  O (35 U.S.C. 8 133)	on.
Status			
1) Responsive to communication(s) filed on <u>06/30</u>	<u>0/03</u> .		
·	s action is non-final.	+	•
3) Since this application is in condition for allowar closed in accordance with the practice under E			s .
Disposition of Claims			•
4) ☐ Claim(s) 1-20 is/are pending in the application. 4a) Of the above claim(s) is/are withdraw 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) 1-20 are subject to restriction and/or expressions.	wn from consideration.		
Application Papers			•
9) The specification is objected to by the Examine	יר.		
10) The drawing(s) filed on is/are: a) acce		Examiner	
Applicant may not request that any objection to the			
Replacement drawing sheet(s) including the correcti			d).
11) The oath or declaration is objected to by the Ex			-,-
Priority under 35 U.S.C. § 119			
<ul> <li>12) Acknowledgment is made of a claim for foreign</li> <li>a) All b) Some * c) None of:</li> <li>1. Certified copies of the priority documents</li> <li>2. Certified copies of the priority documents</li> </ul>	s have been received. s have been received in Application	on No	
3. ☐ Copies of the certified copies of the prior		ed in this National Stage	
application from the International Bureau	* * * * * * * * * * * * * * * * * * * *		
* See the attached detailed Office action for a list of	of the certified copies not receive	d.	
Attachment(s)	to with the grown of the winds to		
Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)	4) Interview Summary ( Paper No(s)/Mail Da 5) Notice of Informal Pa		
Paper No(s)/Mail Date	6) Other:	atent Application (P10-152)	

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## **DETAILED ACTION**

## Election/Restrictions

Restriction to one of the following inventions is required under 35 U. S.C. 121:

- I Claims 1-17, drawn to a phase change memory device, classified in class 257, subclass 355.
- II. Claims 18-20, drawn to semiconductor manufacturing method, classified in class 438, subclass 303.

The inventions are distinct, each from the other because of the following reasons: Inventions II and I are related as process of making and product made. The inventions are distinct if either or both of the following can be shown: (1) that the process as claimed can be used to make another and materially different product or (2) that the product as claimed can be made by another and materially different process (MPEP § 806.05(f)). In the instant case, the device of the group I invention could be made by a materially different process from that of the group II invention, for example, selectively deposit rather than mask and remove a portion of the second dielectric material.

Because these inventions are distinct for the reasons given above and have acquired a separate status in the art as shown by their different classification, restriction for examination purposes as indicated is proper.

Applicant, is advised that the reply to this requirement to be complete must include an election of the invention to be examined even though the requirement be traversed (37 CFR 1.143)

Applicant is reminded that upon the cancellation of claims to a non-elected invention, the inventorship must be amended in compliance with 37 CFR 1.48(b) if one or more of the currently named inventors is no longer an inventor of at least one claim remaining in the application. Any amendment of inventorship must be accompanied by a request under 37 CFR 1.48(b) and by the fee required under 37 CFR 1.17(1).

Any inquiry concerning this communication or earlier communications from the examiner should be directed to David Vu whose telephone number is (571) 272-1798.

The examiner can normally be reached from 8:30 AM- 5:30 PM if attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Nelms can be reached on (571) 272-1787. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 872-9306 for regular communications and (703) 872-9306 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

David Vu

Shulank